

## Memories

The third key component of a microprocessor-based system (besides the CPU and I/O devices).

- Classification
- Physical and external configuration
- Timing
- Types

## Basic Categories

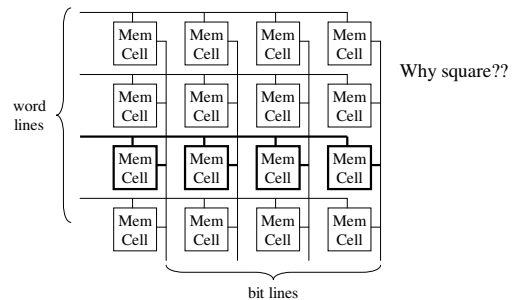
- **Read-Only Memory (ROM):**
  - Can only be read; cannot be modified (written). Contents of ROM chip are set before chip is placed into the system.
- **Random-Access Memory (RAM):**
  - Read/write memory. Although technically inaccurate, term is used for historical reasons. (ROMs are also random access.)
- **Volatile memories**
  - Lose their contents when power is turned off. Typically used to store program while system is running.
- **Non-volatile memories** do not.
  - Required by every system to store instructions that get executed when system powers up (boot code).

## Classification

	ROM	RAM
Volatile		Static RAM (SRAM) Dynamic RAM (DRAM)
Non-volatile	Mask ROM PROM EPROM	EEPROM Flash memory BBSRAM

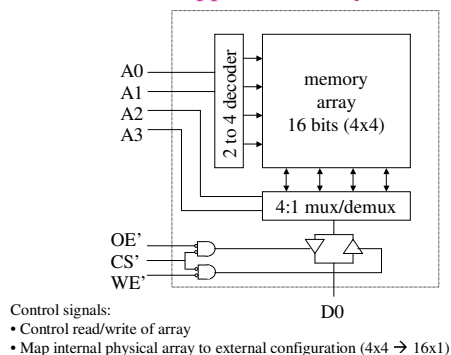
Note that we can write some of these “ROMS”

## Memory Array



Different memory types are distinguished by technology for storing bit in memory cell.

## Support Circuitry



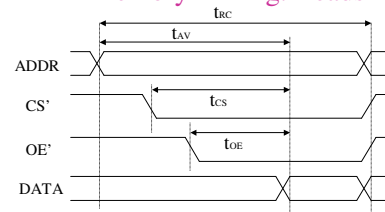
## Interface (1/2)

- **Physical configurations** are typically square.
  - Minimize length word + bit line → minimize access delays.
- **External configurations** are “tall and narrow”. The narrower the configuration, the higher the pin efficiency. (Adding one address pin cuts data pins in half.)
  - Several external configurations available for a given capacity.
  - 64Kbits may be available as 64Kx1, 32Kx2, 16Kx4,...

## Interface (2/2)

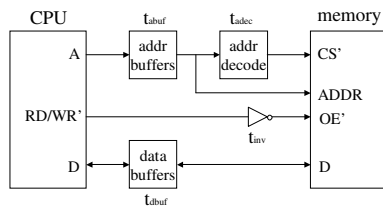
- Chip Select (CS'): Enables device. If not asserted, device ignores all other inputs (sometimes entering low-power mode).
- Write Enable (WE'): Store D0 at specified address.
- Output Enable (OE'): Drive value at specified address onto D0.

## Memory Timing: Reads



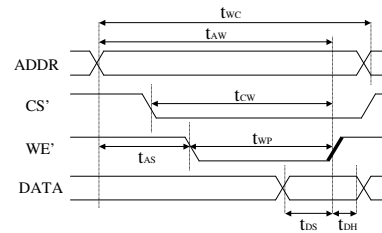
- **Access time:** Time required from start of a read access to valid data output.
  - Access time specified for each of the three conditions required for valid data output (valid address, chip select, output enable)
- Time to valid data out depends on which of these is on critical path.
- **tRC:** Minimum time required from start of one access to start of next.
  - For most memories equal to access time.
  - For DRAMs could exceed 2x. Why?

## System-Level Read Timing



If the CPU starts driving the address and RD/WR' at the same time, what is the access time?

## Memory Timing: Writes

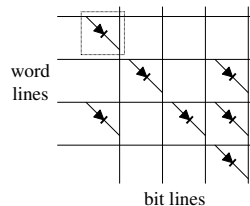


- Write happens on **rising** edge of WE'.
- Separate access times  $t_{AW}$ ,  $t_{CW}$ ,  $t_{WP}$  specified for address valid, CS', WE'.
- Typically,  $t_{AS} = 0$ , meaning that WE' may **not** be asserted **before** address is valid.
- Setup and hold times required for data.
- Write cycle time  $t_{WC}$  is typically in the order of  $t_{AW}$ .

## Mask ROM

- By far the simplest technique.
- Presence/absence of diode at each cell denotes binary value.
- Pattern of diodes defined by mask used in fabrication process.
- Contents fixed when the chip is made; cannot be changed.
- Large setup cost (design mask), small marginal cost.
- Good for high-volume applications where upgrading contents is not an issue.

- What value is stored by presence of diode?
- Why diode rather than simply wire?



## Programmable ROM (PROM)

- Replace the diode in each cell of a Mask ROM by diode + fuse (fusible-link PROM).
- Initial contents are all 1s.
- Users program memory by blowing fuses to create 0s.
- Plug chip into PROM programmer ("burner") device and download data file.
- One-time programmable

### UV Erasable PROM (EPROM)

- Replace PROM fuse with pass transistor controlled by “floating” (i.e. electrically insulated) gate.
- Program by charging gate to switch pass transistor. (Use special “burner” to apply high voltage that overcomes insulation.)
- Erase by discharging all gates using ultraviolet light. (UV photons carry electrons across insulation.)
- Insulation eventually breaks down → limited number of erase/reprogram cycles (100s to 1000s).
- Costly: Requires special package with window.
- Largely displaced by flash memory.

### Electrically Erasable PROM (EEPROM)

- Similar to UV EPROM, but with on-chip circuitry to electrically charge/discharge floating gates (no UV).
- Writable by CPU → really a RAM despite name.
- Reads/writes much like generic RAM: Internal circuitry erases affected byte/word, then reprograms to new value.
- Write cycle in the order of a millisecond.
- High voltage input (e.g. 12V) required for writing.
- Limited number of write cycles (1000s).
- Selective erasing requires extra circuitry in each memory cell → Lower density and higher cost than EPROM.

### Flash Memory

- Electrically erasable like EEPROM, but only in large 8—128K blocks (not a byte at a time).
- Erase circuitry moves out of cells to periphery → substantially better density than EEPROM.
- Reads much like generic RAM
- Writes for locations in erased blocks:
  - write cycle in a few microseconds
  - slower than volatile RAM but faster than EEPROM
- To rewrite locations, must explicitly erase entire block:
  - erase can take several seconds
  - erased blocks can be rewritten a byte at a time
- Floating gate technology → Erase/reprogram cycle limit (10-100K cycles per block)

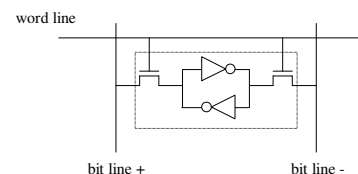
### Flash Applications

- Flash technology has made rapid advances in recent years.
  - cell density rivals DRAM; better than EPROM; much better than EEPROM.
  - multiple gate voltages can encode 2 bits per cell.
  - 1Gb devices available
- ROMs and EPROMs rapidly becoming obsolete.
- Replacing hard disks in some applications.
  - smaller, lighter, faster
  - more reliable (no moving parts)
  - cost effective
- PDAs, cell phones, laptops,...

### Battery-Backed Static RAM (BBSRAM)

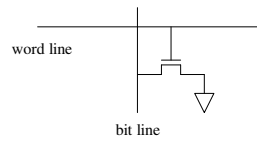
- Standard volatile SRAM device with battery backup.
- Key advantage: writes take as much time as reads.
- Circuitry required to switch battery on/off.

### Static RAM



- Volatile memory
- Each cell is basically a flip-flop
- 4—6 transistors per cell → relatively poor density
- Very fast (access times under 10ns commonplace)
- Reads/writes at same speed

## Dynamic RAM



- One transistor per cell → outstanding density
- Very small charges involved → relatively slow
  - Bit lines must be precharged to detect bit values.
  - Reads are destructive; internal writebacks required.
  - Values must be periodically refreshed or charge will leak away.